

Application No: 10/612,439 Docket No.: Q170-US1

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IN THE SPECIFICATION

Please amend lines 1-20 on page 14 as follows:

REFERENCES

- [1] ~~A. Manthiram, J.B. Goodenough, J. Solid State Chemistry, 71, 349 (1987).~~
- [2] ~~A.K. Padhi, K.S. Nanjundaswamy, J.B. Goodenough, J. Electrochem. Soc., 144, 4 (1997).~~
- [3] ~~A.K. Padhi, K.S. Nanjundaswamy, C. Masquelier, S. Okada, J.B. Goodenough, J. Electrochem. Soc., 144, 5 (1997).~~
- [4] ~~V.B. Nalbandyan, I.L. Shukaev, Russ. J. Inorg. Chem., 32, 3 (1987).~~
- [5] ~~R. Bree, A. Dugast, Mater. Res. Bull., 15, 619 (1980).~~
- [6] ~~H. Huang, S.C. Yin, L.F. Nazar, Electrochemical and Solid State Letters, 4(10), A170 (2001).~~
- [7] ~~R.W. Pekala, J. Mater. Sci., 24, 3221 (1989).~~
- [8] ~~K. Zaghib et al., PCT Patent Application No WO0246101.~~
- [9] ~~M. Armand et al., PCT Patent Application No. WO0227824.~~
- [10] ~~M. Hosooya, K. Takahashi, Y. Fukushima, Sony Corporation Patent, No EP 1193787~~
- [11] ~~S. Yan, Y. Song, P.Y. Zavalij, S. Whittingham, Electrochem. Communications, 4(3), 239 (2002).~~
- [12] ~~P.P. Prosini et al., Solid State Ionics, 2002, 148, 45-51.~~
- [13] ~~M. Takahashi, et al., Document Laid Open to Inspection JP 2001110414.~~
- [14] ~~M. Simoneau, M. Armand, Y. Choquette, K. Zaghib, Hydro-Quebec Laid open Application CA 2,200,998.~~